Technology Center 1795

Amendment dated December 22, 2009
Reply to Office Action dated July 23, 2009

Reply to Office Action dated July 23, 2008

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the

application.

**Listing of Claims:** 

Claim 1 (Currently amended): A system for storing and retrieving

elemental hydrogen, said system comprising:

a housing;

at least one passage connected to said housing for conducting

hydrogen gas into and conducting hydrogen gas out of said housing;

a hydrogen storage member enclosed within said housing, said

hydrogen storage member comprising a mass of porous silicon having

an interior defining interior surfaces of the porous silicon and an exterior

defining exterior surfaces of the porous silicon, at least said interior surfaces

having dangling bond sites at which reversible chemisorption of hydrogen

atoms occurs;

releasing means for causing said chemisorbed hydrogen atoms to be

liberated from said dangling bond sites to be released as hydrogen gas from

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said housing through said at least one passage, wherein said releasing means

comprises one or more is selected from the group consisting of light sources

that emit sufficient photonic energy at a wavelength at which said porous

silicon is sufficiently transparent and said photonic energy is sufficiently

absorbed by said chemisorbed hydrogen atoms to promote liberation of said

chemisorbed hydrogen atoms from said dangling bond sites, or one or more , current sources, voltage sources that create an electric field sufficient to

affect the silicon activation energies and promote liberation of said

chemisorbed hydrogen atoms from said dangling bond sites, or , and

combinations thereof; and

a control unit comprising means for receiving inputs indicative of

operating parameters of said system, and means for issuing outputs that

control said releasing means.

Claim 2 (Previously presented): A system in accordance with claim 1

wherein at least said interior surfaces of said porous silicon have dendritic

spikes or non-conformal growth formed by an additive silicon deposition

process.

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Claim 3 (Previously presented): A system in accordance with claim 1

wherein said at least interior surfaces are bare silicon surfaces at which said

dangling bond sites are exposed.

Claim 4 (Original): A system in accordance with claim 1 comprising a

plurality of said hydrogen storage members.

Claim 5 (Previously presented): A system in accordance with claim 1

wherein said porous silicon defines a layer within at least a first surface portion

of said hydrogen storage member.

Claim 6 (Original): A system in accordance with claim 5 wherein the

percent void volume of said surface layer is about 50%.

Claim 7 (Previously presented): A system in accordance with claim 5

further comprising electronic integrated circuits on a second surface portion of

said hydrogen storage member.

Claim 8 (Currently amended): A system for storing and retrieving

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elemental hydrogen, said system comprising:

a housing;

at least one passage connected to said housing for conducting

hydrogen gas into and conducting hydrogen gas out of said housing:

a hydrogen storage member comprising a porous mesh of crystalline

silicon columns having diameters of about 1 nanometer and silicon surfaces

with dangling bond sites at which reversible chemisorption of hydrogen atoms

occurs, said silicon columns having dendritic spikes or non-conformal growth

formed by an additive silicon deposition process; and

means for liberating said chemisorbed hydrogen atoms from said

dangling bond sites and releasing said liberated hydrogen atoms as hydrogen

gas from said housing through said at least one passage.

Claim 9 (Previously presented): A system in accordance with claim 8

wherein said silicon columns have surfaces on the (111) plane.

Claim 10 (Previously presented): A system in accordance with claim 8

wherein said silicon columns are formed by extrusion of molten silicon to have

surfaces on the (111) plane.

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Claim 11 (Previously presented): A system in accordance with claim

10 wherein said silicon columns are extruded through at least one aperture

that is an integral multiple of the lattice spacing of silicon such that said silicon

columns have a minimum energy configuration suitable for forming a crystal.

Claim 12 (Canceled)

Claim 13 (Currently amended): A system in accordance with claim 8

claim 12- wherein said silicon columns have cross-sectional shapes selected

from the group consisting of triangle, rhombus, square, and circle.

Claim 14 (Previously presented): A system in accordance with claim

10 wherein said silicon columns have roughened surfaces.

Claim 15 (Previously presented): A system in accordance with claim 8

further comprising a control unit comprising means for receiving inputs

indicative of operating parameters of said system, and means for issuing

outputs that control said liberating means.

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Claim 16 (Currently amended): A system in accordance with claim 15

wherein said liberating means comprises at least one source is selected from

the group consisting of light sources, <del>current sources,</del> voltage sources, and

combinations thereof, and said at least one source promotes the liberation of

liberating means liberates said chemisorbed hydrogen atoms from said

dangling bond sites by passing photonic energy through said porous mesh,

passing electrical current through said porous mesh, or creating an electrical

field across said porous mesh.

Claim 17 (Previously presented): A system in accordance with claim 1,

wherein said releasing means comprises a light-emitting diode.

Claim 18 (Currently amended): A system in accordance with claim 1,

wherein said releasing means comprises a light source that emits photon

energy at a wavelength of about 660 nanometers and transmits said photon

energy through said porous silicon and onto said interior surfaces of said

porous silicon to promote the liberation of liberate said chemisorbed

hydrogen atoms from said dangling bond sites on said interior surfaces.

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Claim 19 (Previously presented): A system in accordance with claim 1

wherein said porous silicon is in a monocrystalline form.

Claim 20 (Previously presented): A system in accordance with claim

19 wherein said porous silicon is formed in a silicon wafer.

Claim 21 (Previously presented): A system in accordance with claim 1

wherein said porous silicon is in a polycrystalline form.

Claim 22 (Previously presented): A system in accordance with claim 1

wherein said porous silicon has been treated by a process selected from the

group consisting of crushing, milling, treatment with hydrofluoric acid and

methanol in the presence of electric current, treatment with potassium

hydroxide, treatment with hydrazine, wet etching, dry etching, deposition of a

noble metal such as palladium or platinum, conformal vapor deposition of

silicon, and non-conformal vapor deposition of silicon.

Claim 23 (Previously presented): A system in accordance with claim 1

wherein said porous silicon is derived from molten silicon by crystallization.

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Claim 24 (Previously presented): A system in accordance with claim 1

wherein said porous silicon is derived from silicon waste obtained from a

silicon process waste stream.

Claims 25-37 (Canceled)

Claim 38 (Currently amended): A system in accordance with claim 1,

wherein said releasing means promotes the liberation of <del>liberates</del> said

chemisorbed hydrogen atoms from said dangling bond sites by passing

photonic energy through said porous silicon. passing electrical current

through said porous silicon, or creating an electrical field across said porous

silicon.

Claim 39 (Previously presented): A system in accordance with claim 1,

wherein said control unit further comprises means for controlling the silicon

activation energy of hydrogen on said porous silicon of said hydrogen storage

member.

Claim 40 (Previously presented): A system in accordance with claim

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15, wherein said control unit further comprises means for controlling the silicon

activation energy of hydrogen on said porous mesh of crystalline silicon

columns of said hydrogen storage member.

Claim 41 (Currently amended): A system in accordance with claim 1,

wherein structures within said interior -surfaces- of said porous silicon have

has feature sizes of about one nanometer.

Claim 42 (Previously presented): A system in accordance with claim 1,

wherein said interior surfaces of said porous silicon further comprise etched

pits therein.

Claim 43 (Previously presented): A system in accordance with claim 1,

wherein said releasing means is disposed on the mass of porous silicon.

Claim 44 (Currently amended): A system in accordance with claim 1,

wherein said releasing means comprises a light source that promotes the

liberation of <del>liberates</del> said chemisorbed hydrogen atoms from said dangling

bond sites by passing photonic energy through said porous silicon.

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Claim 45 (Currently amended): A system in accordance with claim 1,

wherein said releasing means further comprises a heat -current- source that

promotes the liberation of <del>liberates</del> said chemisorbed hydrogen atoms from

said dangling bond sites by passing electrical current through said porous

silicon.

Claim 46 (Currently amended): A system in accordance with claim 1,

wherein said releasing means comprises a voltage source that promotes the

liberation of liberates said chemisorbed hydrogen atoms from said dangling

bond sites by creating an electrical field across said porous silicon.

Claim 47 (Currently amended): A system in accordance with claim 8,

wherein said liberating means comprises a light source that promotes the

liberation of -liberates- said chemisorbed hydrogen atoms from said dangling

bond sites by passing photonic energy through said porous mesh.

Claim 48 (Currently amended): A system in accordance with claim 16.

claim 8, wherein said liberating means further comprises a heat -current-

source that promotes the liberation of <del>liberates</del> said chemisorbed hydrogen

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atoms from said dangling bond sites by passing electrical current through said

porous mesh.

Claim 49 (Currently amended): A system in accordance with claim 8,

wherein said liberating means comprises a voltage source that promotes the

liberation of -liberates- said chemisorbed hydrogen atoms from said dangling

bond sites by creating an electrical field across said porous mesh.

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